

Amendments to the Specification:

Please replace the paragraph beginning at page 19, lines 19-23 with the following amended paragraph:

In addition, it is preferable that the thickness of the ~~second~~ first amorphous semiconductor film 12 be made half or less of the thickness of the ~~first~~ second amorphous semiconductor film 11, and it is desirable that the total thickness of a laminated film made of the first amorphous semiconductor film 11 and the second amorphous semiconductor film 12 be made 20-100 nm (preferably 30-60 nm).